

## GaAs PHEMT MMIC MEDIUM POWER AMPLIFIER, 34 - 42 GHz

### Typical Applications

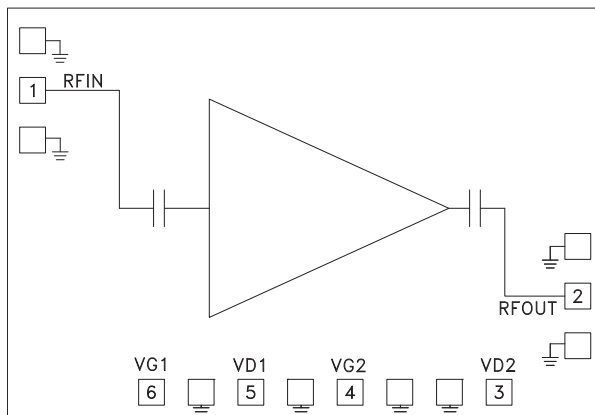
The HMC-ABH264 is ideal for:

- Point-to-Point Radios
- Point-to-Multi-Point Radios
- VSAT
- Military & Space

### Features

- High Output IP3: 29 dBm
- High P1dB: 18 dBm
- High Gain: 18.5 dB
- Bias Supply: +5V
- 50 Ohm Matched Input/Output
- Die Size: 2.4 x 1.64 x 0.1 mm

### Functional Diagram



### General Description

The HMC-ABH264 is a high dynamic range GaAs PHEMT MMIC Medium Power Amplifier which operates between 34 and 42 GHz. The HMC-ABH264 provides 18.5 dB of gain, and an output power of 18 dBm at 1 dB compression from a +5V supply. The HMC-ABH264 amplifier can easily be integrated into Multi-Chip-Modules (MCMs) due to its small size. This compact medium power amplifier die delivers consistent output power and excellent gain flatness across its rated bandwidth. All data herein is measured with the chip in a 50 Ohm test fixture connected via 0.025mm (1 mil) diameter wire bonds of minimal length 0.31mm (12 mils).

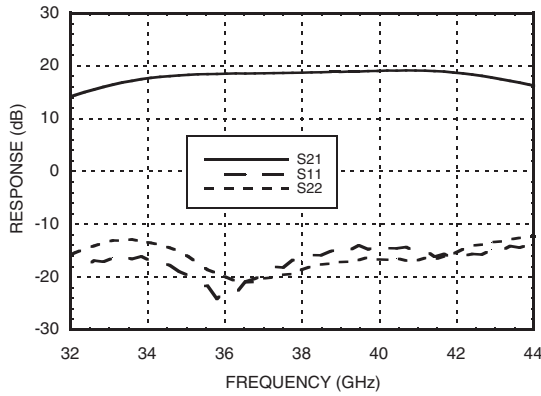
### Electrical Specifications, $T_A = +25^\circ \text{C}$ , $V_{d1} = V_{d2} = V_{dd} = 5\text{V}$ , $I_{dd\text{TOTAL}} = 120\text{mA}^*$

Parameter	Min.	Typ.	Max.	Min.	Typ.	Max.	Units
Frequency Range	34 - 40		40 - 42				GHz
Gain	16	18.5		16	18.5		dB
Gain Variation Over Temperature		0.018			0.022		dB/°C
Input Return Loss		16			12		dB
Output Return Loss		16			15		dB
Output Power for 1 dB Compression (P1dB)	16.5	18		16	17		dBm
Saturated Output Power (Psat)		20.5			20.5		dBm
Output Third Order Intercept (IP3)		29			27.5		dBm
Noise Figure		6.5			6.5		dB
Total Supply Current (Idd)(Vdd = 5V, Vgg = -0.45V Typ.)		120	140		120	140	mA

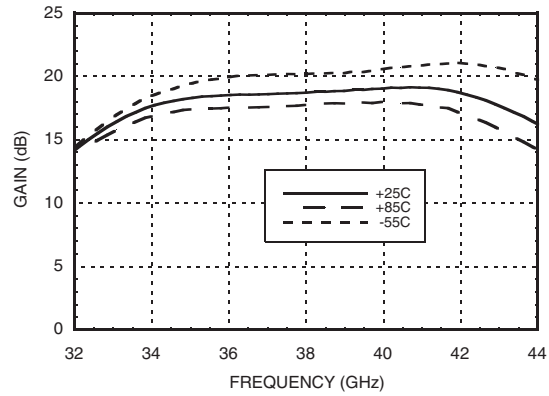
\* Adjust Vgg between -2 to 0V to achieve Idd = 120mA typical.

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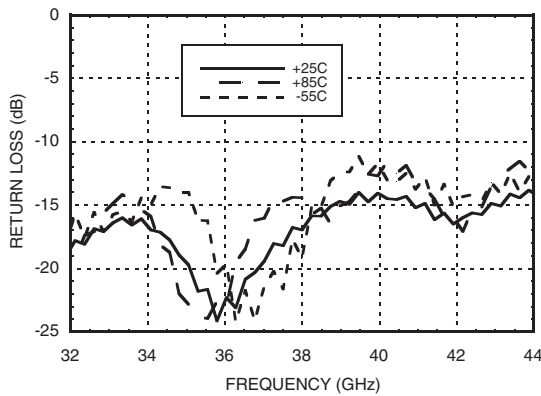
**Broadband Gain &  
Return Loss vs. Frequency**



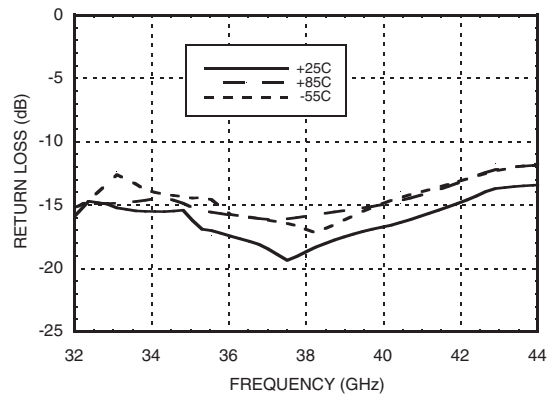
**Gain vs. Temperature**



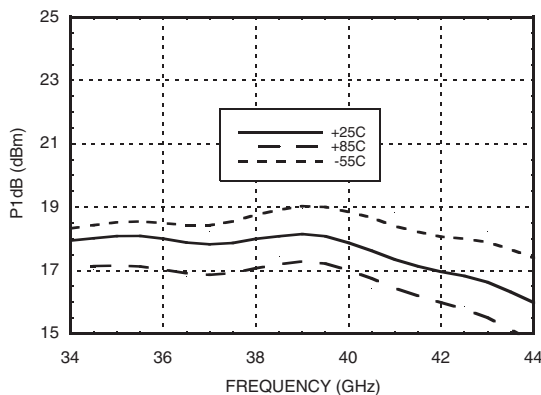
**Input Return Loss vs. Temperature**



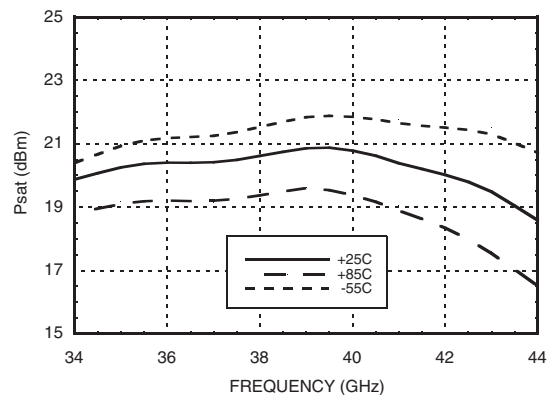
**Output Return Loss vs. Temperature**



**Output P1dB vs. Temperature**

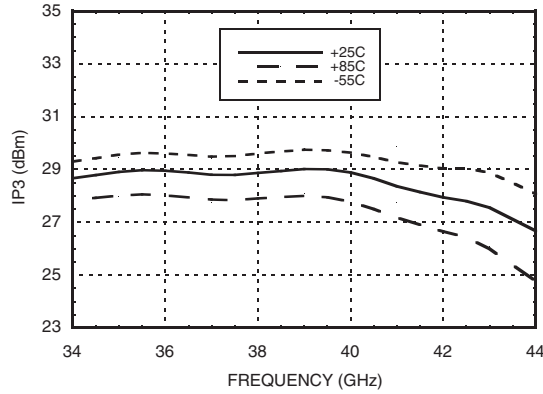


**Psat vs. Temperature**

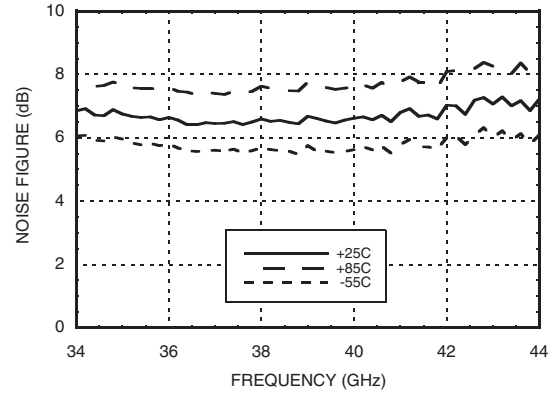


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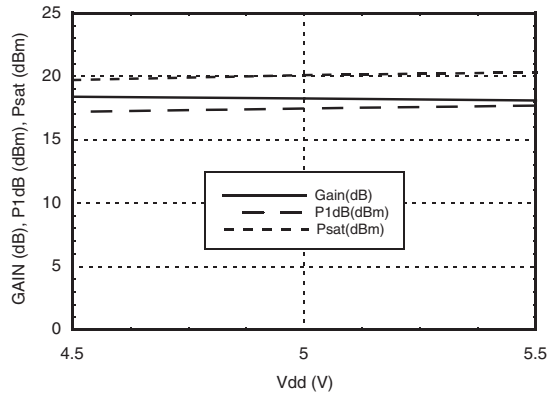
**Output IP3 vs. Temperature**



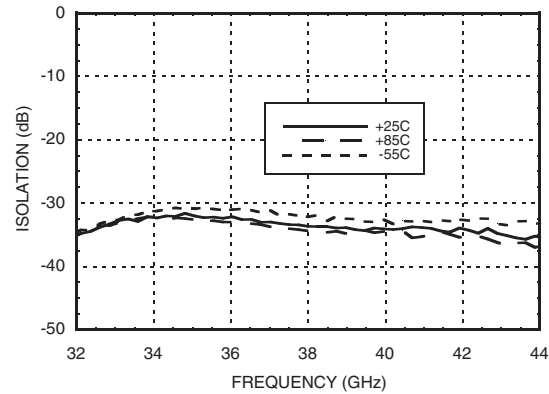
**Noise Figure vs. Temperature**



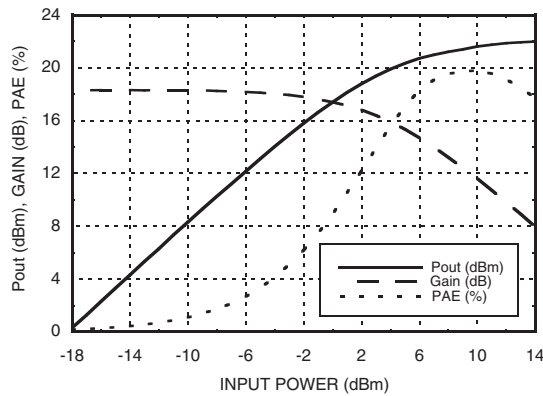
**Gain & Power vs.  
Supply Voltage @ 38 GHz, I<sub>dd</sub>= 120mA**



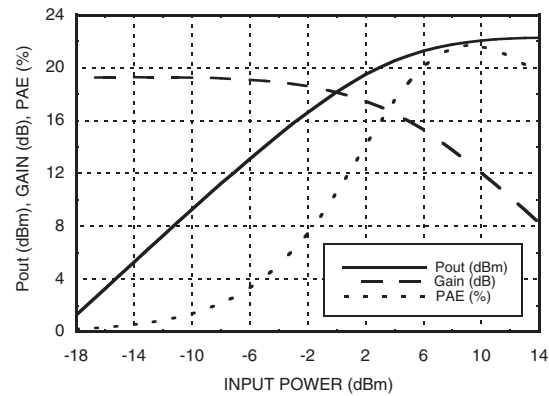
**Reverse Isolation vs. Temperature**



**Power Compression @ 36 GHz**



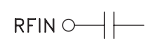
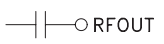
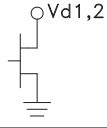
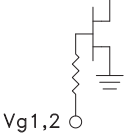

**Power Compression @ 40 GHz**



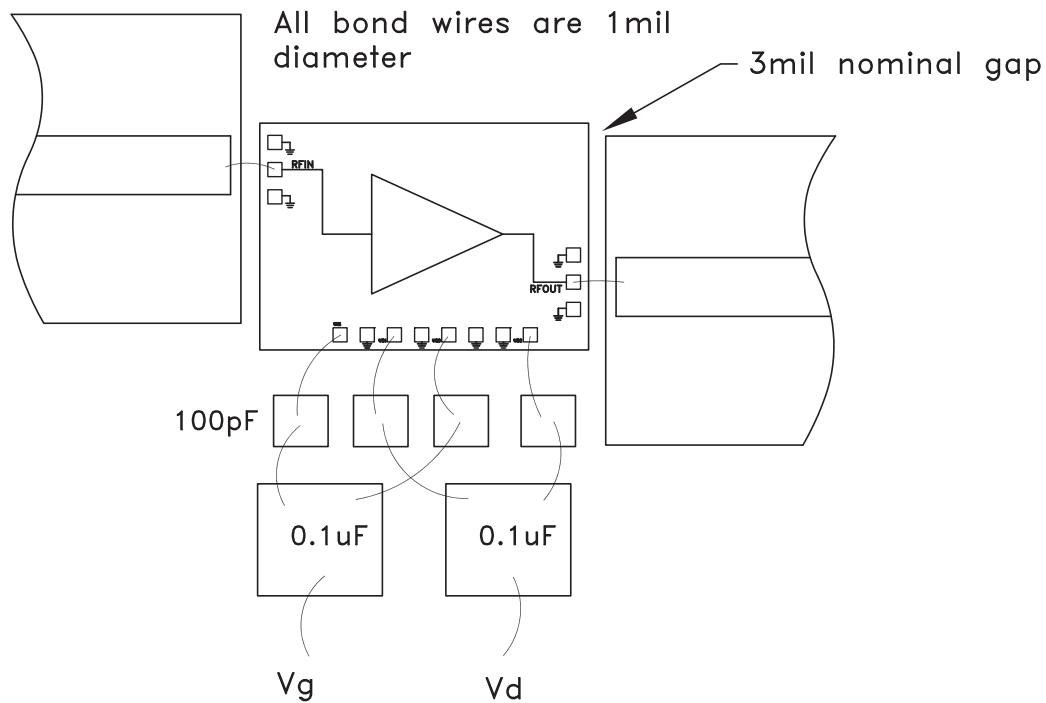


## GaAs PHEMT MMIC MEDIUM POWER AMPLIFIER, 34 - 42 GHz

### Pad Descriptions

Pad Number	Function	Description	Interface Schematic
1	RFIN	This pad is AC coupled and matched to 50 Ohms	
2	RFOUT	This pad is AC coupled and matched to 50 Ohms.	
3, 5	Vd, 1	Power Supply Voltage for the amplifier. External bypass capacitors of 100 pF and 0.01 μF are required.	
4, 6	Vg, 1	Gate control for amplifier. Adjust to achieve I <sub>dd</sub> of 120mA. Please follow "MMIC Amplifier Biasing Procedure" Application Note. External bypass capacitors of 100 pF and 0.01 μF are required.	
Die Bottom	GND	Die bottom must be connected to RF/DC ground.	

### Assembly Diagram



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**Mounting & Bonding Techniques for Millimeterwave GaAs MMICs**

The die should be attached directly to the ground plane eutectically or with conductive epoxy (see HMC general Handling, Mounting, Bonding Note).

50 Ohm Microstrip transmission lines on 0.127mm (5 mil) thick alumina thin film substrates are recommended for bringing RF to and from the chip (Figure 1). If 0.254mm (10 mil) thick alumina thin film substrates must be used, the die should be raised 0.150mm (6 mils) so that the surface of the die is coplanar with the surface of the substrate. One way to accomplish this is to attach the 0.102mm (4 mil) thick die to a 0.150mm (6 mil) thick molybdenum heat spreader (moly-tab) which is then attached to the ground plane (Figure 2).

Microstrip substrates should be brought as close to the die as possible in order to minimize bond wire length. Typical die-to-substrate spacing is 0.076mm to 0.152 mm (3 to 6 mils).

**Handling Precautions**

Follow these precautions to avoid permanent damage.

**Storage:** All bare die are placed in either Waffle or Gel based ESD protective containers, and then sealed in an ESD protective bag for shipment. Once the sealed ESD protective bag has been opened, all die should be stored in a dry nitrogen environment.

**Cleanliness:** Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.

**Static Sensitivity:** Follow ESD precautions to protect against ESD strikes.

**Transients:** Suppress instrument and bias supply transients while bias is applied. Use shielded signal and bias cables to minimize inductive pick-up.

**General Handling:** Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers. The surface of the chip may have fragile air bridges and should not be touched with vacuum collet, tweezers, or fingers.

**Mounting**

The chip is back-metallized and can be die mounted with AuSn eutectic preforms or with electrically conductive epoxy. The mounting surface should be clean and flat.

**Eutectic Die Attach:** A 80/20 gold tin preform is recommended with a work surface temperature of 255 °C and a tool temperature of 265 °C. When hot 90/10 nitrogen/hydrogen gas is applied, tool tip temperature should be 290 °C. DO NOT expose the chip to a temperature greater than 320 °C for more than 20 seconds. No more than 3 seconds of scrubbing should be required for attachment.

**Epoxy Die Attach:** Apply a minimum amount of epoxy to the mounting surface so that a thin epoxy fillet is observed around the perimeter of the chip once it is placed into position. Cure epoxy per the manufacturer's schedule.

**Wire Bonding**

Ball or wedge bond with 0.025mm (1 mil) diameter pure gold wire. Thermosonic wirebonding with a nominal stage temperature of 150 °C and a ball bonding force of 40 to 50 grams or wedge bonding force of 18 to 22 grams is recommended. Use the minimum level of ultrasonic energy to achieve reliable wirebonds. Wirebonds should be started on the chip and terminated on the package or substrate. All bonds should be as short as possible <0.31mm (12 mils).

